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(54) RESIN COMPOSITION

(57)Abstract:

PURPOSE: To obtain a resin composition excellent in heat resistance, weathering resistance, chemical resistance, mechanical properties and moldability, comprising a specified copolymer, a specified copolymer composition and a third component. CONSTITUTION: This resin composition is formed from [I] a copolymer obtained by polymerizing a monomer A such as a maleimide monomer A-1 or an unsaturated carboxylic acid monomer A-2 with a monomer B such as an aromatic vinyl monomer B-1, an unsaturated nitrile monomer B-2 or an unsaturated carboxylic ester monomer B-3 and a monomer C copolymerizable therewith in the presence or absence of a thermoplastic resin and/or a rubbery polymer (hereinafter referred to as X) and having a composition (except component X) represented by the formulas I and II, [II] a copolymer composition which comprises a copolymer obtained by polymerizing B-1, B-3 and monomer D copolymerizable therewith in the presence or absence of component X and having an average composition (except component X) of formulas III and IV, and [III] component X. The mixing ratio of components IWIII is in the range represented by formulas V and VI.



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